PHYSICS-II

Assignment-5

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Baten: F2

Le for intrinsic semiconductor, concentration of e-in conduction Band is equal to concentration of holes in value bound

$$n_0 = h_1^\circ = N_e e^{-\frac{(\xi_e - \xi_{pi})}{KT}} - \hat{U}$$

$$S_0 = \hat{U} = N_v e^{-\frac{(\xi_{pi} - \xi_{v})}{KT}} - \hat{U}$$

(hi= fi)-(iii). For Envolusie semilondulor

from (i), (ii), (iii), we get
$$\rightarrow$$

 $N_{\rm p}^2 = N_{\rm e} e^{-(\xi_{\rm c} - \xi_{\rm e})}$, $N_{\rm v} e^{-(\xi_{\rm p}' - \xi_{\rm v})}$
 $N_{\rm p}^2 = N_{\rm e} N_{\rm v} e^{-(\xi_{\rm c} - \xi_{\rm v})}$

Now Band Gap Energy. Ec-Ev=Eg

ni2 = NeNse-egler

Independent of Fermi-level.

The intrinste fermi-level position
$$\rightarrow ni = gi$$

 $N_c = \frac{(\epsilon_c - \epsilon_s i)}{\kappa \tau} = N_J e^{-(\frac{\epsilon_f i}{\kappa \tau} - \epsilon_V)}$

Cy = \f(\ell_{\chi}(\ell_{\chi} - \ell_{\chi}) + \f\krtln(\frac{mp*}{mov*})^{3/2} - (iv)

At zeno Kelvin ->
Emidgap = {(Ec+Ev)

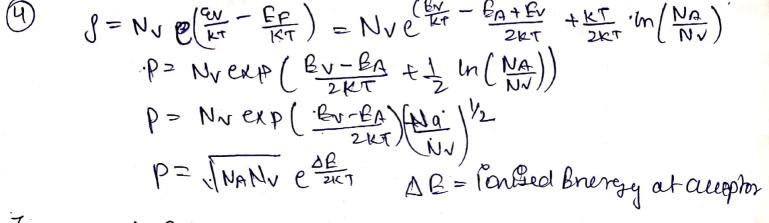
on putting equ'n (iii) inito me get

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2= Couvier Concentration and fermi level on n-type semicondutor-Ec Corclustion band Valence Bound Nd = Concentration of donor atoms in donor level Nat = concentration of British donos atom, Na = Concentration of undonised donor atom. nles comentration in conduction Band > Ne e-(E-Ep) Not +P=n Nd+≈ n or p≈ n;2/NdT - (2) The probability of flooling unlonged donor atom at Energy tevel Ed Bo given as -Md = F(Ed) > Na+ = Na[1-F(Ed)] as Nat + Na = Nd NdT=Nd[1-1+e-(Ec-Ep)]=Nd. e(Ed-Ep) BR-Ed << KT (assumption) From (2) $N_c e^{-\left(\frac{\mathcal{E}_c - \mathcal{E}_t}{KT}\right)} = N_d e^{\left(\frac{\mathcal{E}_d - \mathcal{E}_p}{KT}\right)}$ On solving \rightarrow $E_f = \underbrace{E_d + E_c}_{N_c} + \underbrace{1}_{K_r \ln\left(\frac{N_d}{N_c}\right)}$ But Nc = 2 [28 m * KT] 3/2 80, Ep = Fd+Ec + 1KT h [Ndh3 2 (217m* KT)812] 80, Pp= Edtec + 1 KT [Nah3 2/217 m* KT)3/2

free e concentration in londwetten Bond would be n = No e-(& - &p) Substituting Ep = Ed + Ec + Ict In [NO] n = Ne et Ed+ Ec + 2 m [Nd]] nz Nond ezkit AE = Er-Ed (Ionified Energy of Donos extom) Carrier concentration and fermi-level in ptype semicondulos However of alleptance sufficiently. J= Nre(tBv-EP)/KT Brised, NA = NA But np=n,02 P= Natn n= N= npl from fermi level and conductivity in ptype remilordula If all acrophors are consed of Na acceptance are Poulsed PX NA= NV e EV-EL JXNA = NAP(EA) = NA[1+ e(EA - EA) KT] Ev-Ep= Kth (Nd) By assumption -> Ep=Ev-ktln (Nd) PA-EP>TKT J. NA = NA eCEP-EA)/KT P=NA=NAe(ER-EA)/KT NA e(Er-BA)/KT = Ny e(Ev-EA)/KT By solving -> Ep = EA-EV - KI In (NA) · Since Nv = 2 (20 m*h kT) 3/2 => Ep = Ex+Fv - KT IN NAh8 (20 m*hKT) 3/2 free es concentration in conduction bandwould ke P= Nv e Ev-FF ·Ep = FA+EV - KT In (NA)

3 Age



30 Hall Effect

When a material coverying current is subjected to magnetic field in a direction perpendicular to direction of current, an Ep 1st developed across the material is a direction perpendicular to both the direction of magnetic field and current direction. This phenomenon is called flail- Effect.

Application

1) Determination of type semiconductor-

that weffficient Rr is regative for a ntype semiconductor and eve for p-type. Thus the sign of Hall wefficient can be used to different whether a given semiconductor is n-type/p-type.

2) Calculation of Carrier Concentration-RH = -te > n-type RH > te > p-type.

4) Measurement of magnetic flux density-

Hall voltage x magnisher pux density B for aghen lursent I so Mall Effect as the basis for clesing of Magnetic Plux Density Method

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